

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of: Marc Schaepekens  
Serial No.:  
Filed:  
Group Art Unit:

"EXPRESS MAIL" MAILING

LABEL NUMBER

EV 300768025 US

For: APPARATUS AND METHOD FOR DEPOSITING LARGE  
AREA COATINGS ON NON-PLANAR SURFACES

INFORMATION DISCLOSURE STATEMENT

Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 2313-1450

SIR:

This Information Disclosure Statement is being filed under 37 C.F.R. §1.56 for a continuing application, which relies on the filing date of its parent application, such parent application being identified as:

U.S. Patent Application Serial No.: 09/683,148

Examiner: Parviz Hassanzadeh

Filed: November 27, 2001

Allowed Date: September 8, 2003

Inventor(s): Marc Schaepekens

Confirmation No.: 5980

Title: APPARATUS AND METHOD FOR DEPOSITING  
LARGE AREA COATINGS ON NON-PLANAR  
SURFACES

Group Art Unit: 1763

Enclosed are copies of Form PTO-892 and PTO-1449 listing all "prior art" cited and submitted in the parent application Pursuant to 37 C.F.R. §1.98(d), no actual copies of the documents listed are being furnished to the PTO with this Information Disclosure Statement.

Respectfully submitted,



Robert P. Santandrea  
Patent Counsel

DATE: December 9, 2003

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FORM PTO-1449 (REV. 7-80)		US. DEPARTMENT OF COMMERCE PATENT AND TRADEMARK OFFICE		ATTY. DOCKET NO. RD-28,484-1	SERIAL NO. 09/683,148		
INFORMATION DISCLOSURE STATEMENT BY APPLICANT <u>LIST OF ITEMS</u>				Applicant Marc (NMN) Schaepkens			
				Filing Date 11/27/01	Group 1763		
<b>U.S. PATENT DOCUMENTS &amp; U.S. PATENT APPLICATION PUBLICATIONS</b>							
*EXAMINER INITIAL	DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE	
	A1	4,871,580	Schram et al.				
	A2	4,957,062	Schuurmans et al.				
	A3	5,120,568	Schuurmans et al.				
	A4	6,213,049	Yang				
	A5						
<b>FOREIGN PATENT DOCUMENTS</b>							
		DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUBCLASS	TRANSLATION YES      NO
	B1						
	B2						
<b>OTHER INFORMATION</b> (Including Author, Title, Date, Pertinent Pages, etc.)							
	C1	<i>"Temperature and Growth-Rate Effects on the Hydrogen Incorporation in Hydrogenated Amorphous Silicon"</i> , WMM Kessels et al., Department of Applied Physics, Eindhoven University of Technology, 1998, pp 29-33.					
	C2	<i>"Improvement of Hydrogenated Amorphous Silicon Properties With Increasing Contribution of SiH<sub>3</sub> to Film Growth"</i> , WMM Kessels et al., Department of Applied Physics, Eindhoven University of technology, pp 107-110.					
	C3	<i>Application Serial No. 09/681, 820, filed June 11, 2001, "Apparatus and Method for Large Area Chemical Vapor Deposition Using Multiple Expanding Thermal Plasma Generators".</i>					
	C4	<i>Application Serial No. 09/683,149, Specification RD-28,667 – "Apparatus and Method for Depositing Large Area Coatings on Planar Surfaces"</i> , Marc (NMN) Schaepkens.					
	C5						
	C6						
EXAMINER					DATE CONSIDERED		
EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant							

<b>Notice of References Cited</b>	Application/Control No. 09/683,148	Applicant(s)/Patent Under Reexamination SCHAEPKENS, MARC	
	Examiner Parviz Hassanzadeh	Art Unit 1763	Page 1 of 1

**U.S. PATENT DOCUMENTS**

*		Document Number Country Code-Number-Kind Code	Date MM-YYYY	Name	Classification
	A	US-6,383,953 B2	05-2002	Hwang	438/788
	B	US-6,397,776 B1	06-2002	Yang et al	118/723 MP
	C	US-6,143,078	11-2000	Ishikawa et al	118/715
	D	US-5,560,779	10-1996	Knowles et al	118/723 MP
	E	US-6,487,986 B1	12-2002	Liehr et al	118/723 MW
	F	US-6,013,155	01-2000	McMillin et al	156/345.43
	G	US-			
	H	US-			
	I	US-			
	J	US-			
	K	US-			
	L	US-			
	M	US-			

**FOREIGN PATENT DOCUMENTS**

*		Document Number Country Code-Number-Kind Code	Date MM-YYYY	Country	Name	Classification
	N	JP-63-187619-A	08-1998	JP	Mochizuki	H01L 21/205
	O					
	P					
	Q					
	R					
	S					
	T					

**NON-PATENT DOCUMENTS**

*		Include as applicable: Author, Title Date, Publisher, Edition or Volume, Pertinent Pages)
	U	
	V	
	W	
	X	

\*A copy of this reference is not being furnished with this Office action. (See MPEP § 707.05(a).)  
Dates in MM-YYYY format are publication dates. Classifications may be US or foreign.